779. Polyfluoroalkyl Compounds of Silicon. Part III.¹ A Polyfluoroalkyl Silicone.

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Liquid-phase photochemical reaction of methyldichlorosilane with tetrafluoroethylene gives the compound $CHF_2 \cdot CF_2 \cdot SiMeCl_2$ quantitatively; reaction in the vapour phase yields mainly $CHF_2 \cdot CF_2 \cdot [CF_2 \cdot CF_2]_n \cdot SiMeCl_2$. Aqueous hydrolysis of the 1:1 adduct gives the polyfluoroalkyl silicone $[(CHF_2 \cdot CF_2)SiMe \cdot O \cdot]_n$. Thermal decomposition of the unfractionated silicone begins at 200° but is incomplete at 320°; trifluoroethylene is the main volatile product. Aqueous alkaline hydrolysis of methyl-1:1:2:2tetrafluoroethyldichlorosilane, or of the silicone derived from it, gives 1:1:2:2-tetrafluoroethane.

A FLUORO-OLEFIN such as tetrafluoroethylene is sensitive to attack by silicon radicals such as \cdot SiCl₃ or \cdot SiHMe₂ which thus initiate a chain reaction.^{1,2} Chain transfer by abstraction of hydrogen from an \geq SiH group by a $-CF_2 \cdot CF_2 \cdot$ radical occurs readily so that polyfluoroalkylsilicon compounds CHF₂·CF₂·Si \leq can be obtained in good yield.^{1,2} This type of reaction has now been extended to the synthesis of methyl-1:1:2:2-tetrafluoro-ethyldichlorosilane, the precursor of a polyfluoroalkylsilicone:

$$MeSiHCl_{2} \xrightarrow{h\nu} \cdot SiMeCl_{2} + H \cdot$$

$$\cdot SiMeCl_{2} + C_{2}F_{4} \longrightarrow SiMeCl_{2} \cdot CF_{2} \cdot CF_{2} \cdot \underbrace{MeSiHCl_{2}}_{} CHF_{2} \cdot CF_{2} \cdot SiMeCl_{2} (I) + \cdot SiMeCl_{2}, etc.$$

Exposure of a solution of tetrafluoroethylene in methyldichlorosilane to ultraviolet light of wavelength >2200 Å causes rapid reaction to give methyl-1:1:2:2-tetrafluoro-ethyldichlorosilane (I) essentially quantitatively within a few hours. The propagation reaction,

$$SiMeCl_2 \cdot CF_2 \cdot CF_2 \cdot \underbrace{ \ }^{nC_3F_4} \qquad \qquad SiMeCl_2 \cdot [CF_2 \cdot CF_2]_n \cdot CF_2 \cdot CF_2 \cdot CF_2$$

is prevented by use of a 200% excess of methyldichlorosilane as solvent. It is noteworthy that hydrogen is not a product, indicating that the hydrogen atoms react preferentially with tetrafluoroethylene.¹

Photochemical reaction of an excess of methyldichlorosilane with tetrafluoroethylene in the vapour phase is extremely fast. The propagation step is not prevented as easily as for the liquid-phase reaction, and methyl 1:1:2:2-tetrafluoroethyldichlorosilane is formed in only 20% yield, with the compounds $CHF_2 \cdot CF_2 \cdot [CF_2 \cdot CF_2]_n \cdot SiMeCl_2$ as the main product, although increase in the ratio of methyldichlorosilane to tetrafluoroethylene would doubtless improve the yield of the 1:1 adduct.

Aqueous hydrolysis of methyl-1:1:2:2-tetrafluoroethyldichlorosilane gives the polyfluoroalkylsilicone (II) quantitatively. This is a colourless viscous ether-soluble liquid of b. p. >200°. It is stable to water and acids, but is readily cleaved by aqueous sodium hydroxide to give 1:1:2:2-tetrafluoroethane quantitatively, together with the polysiloxane $[CH_3 \cdot SiO_{1.5}]_n$ formed by cross-linking of the intermediate polysilanol (III).

Methyl-1:1:2:2-tetrafluoroethyldichlorosilane similarly yields 1:1:2:2-tetrafluoroethane with aqueous alkali. The electron-releasing methyl group thus does not offset the

¹ Part II, Geyer and Haszeldine, J., 1957, 1038.

² Haszeldine and Marklow, J., 1956, 962.

inductive pull of the polyfluoroalkyl group, which has pseudohalogen character and makes the silicon atom sensitive to nucleophilic attack.²

The infrared spectra of compounds (I) and (II) are very similar, but the latter shows a new strong band at 1156 cm.⁻¹ which is attributed to the -Si-O-Si- vibration. The C-F stretching vibration is at 1110 cm.⁻¹.

A preliminary investigation has been made of the thermal stability of the silicone (II). Partial decomposition of the unfractionated (by distillation or solvent-extraction) silicone occurred at 200° in vacuo, and further decomposition set in when the temperature was raised to 260°, then $\Im 20^{\circ}$. The gaseous product at each temperature was a mixture of trifluoroethylene and compounds (e.g., silicon tetrafluoride) soluble in aqueous alkali. The total yield of trifluoroethylene was 47%. Pyrolysis of the silicone thus involves abstraction of β -fluorine by silicon with fission of the Si⁻CF₂ bond. The compounds CF₂Cl·CF₂·SiCl₃ and CHF₂·CF₂·SiCl₃ similarly yield chlorotrifluoroethylene and trifluoroethylene respectively on pyrolysis.² Thermal degradation of the silicon (II) is not complete at any one temperature, however, and some of the silicone is a mixture of polymers of different chain length and cyclic siloxanes. The general problem of the effect of structure on the thermal stability of polyfluoroalkylsilicon compounds is now under investigation, using suitable reference compounds and fractionated polyfluoroalkylsilicones and polysiloxanes.

EXPERIMENTAL

Reaction of Methyldichlorosilane with Tetrafluoroethylene.—(a) In silica apparatus. Methyldichlorosilane (12·25 g., 106·5 mmoles), freshly distilled in vacuo with precautions to remove traces of air (Found: M, 115. Calc. for $CH_4Cl_2Si: M$, 115) and tetrafluoroethylene (3·55 g., $35\cdot5$ mmoles) (ratio $C_2F_4: CH_3SiHCl_2 = 1:3$) in a sealed 200-ml. silica tube were exposed to ultraviolet light from a Hanovia S 250 arc for 64 hr. The main reaction is over within a few hours. Both liquid and vapour phase were irradiated. No hydrogen could be detected when the tube was connected to an apparatus for the manipulation of gases and opened; even traces would have been detected by the sensitive techniques available. Distillation gave unchanged methyldichlorosilane (8·2 g., 77%) and methyl-1: 1:2:2-tetrafluoroethyldichlorosilane (7·5 g., $34\cdot9$ mmoles, 98%) (Found: C, $17\cdot0$; H, $2\cdot0$. $C_3H_4Cl_2F_4Si$ requires C, $16\cdot7$; H, $1\cdot9\%$), b. p. $95\cdot5-96\cdot0^\circ/770$ mm. Only a very small amount of liquid of higher b. p., probably $CHF_2^{\cdot}[CF_2]_3^{\cdot}SiMeCl_2$, remained.

(b) In a 20-1. flask. The apparatus described earlier ³ for photochemical reactions on a molar scale was used. The reaction of methyldichlorosilane (50.6 g., 440 mmoles) with tetra-fluoroethylene (17.0 g., 170 mmoles) (ratio C_2F_4 : MeSiHCl₂ == 1 : 2.59) in the vapour phase was very rapid and globules of product formed as a mist as soon as the ultraviolet light was turned on. Reaction was complete after 5—6 hr., and irradiation was continued for a total of 42 hr. without further change. Distillation gave unchanged methyldichlorosilane (31.0 g., 61%), methyl-1 : 1 : 2 : 2-tetrafluoroethyldichlorosilane (7.28 g., 20%), b. p. 96°, a fraction (18.2 g.) of b. p. 98—158°, and a still residue (3.0 g.). The 20-1. flask contained 5 g. of a viscous oil which could not be removed by distillation *in vacuo*. Redistillation of the material of b. p. 98—158° gave a fraction, b. p. 140—144°, which is probably CHF₂·[CF₂]₃·SiMeCl₂, since when hydrolysed with 10% aqueous sodium hydroxide it liberated 1 : 1 : 2 : 2 : 3 : 3 : 4 : 4-octafluorobutane (Found: *M*, 197. Calc. for C₄H₂F₈: *M*, 202), identified by means of its infrared spectrum.¹

Hydrolysis of Methyl-1: 1: 2: 2-tetrafluoroethyldichlorosilane.—(a) Aqueous hydrolysis. The silane (0.310 g., 1.44 mmoles) was shaken for 30 min. with water (10 ml.) in a 500-ml. bulb in absence of air. No volatile products were detected. Extraction of the solution with ether and removal of the ether from the dried (Na₂SO₄) extract at room temperature gave the *silicone* (II) (0.225 g., 1.40 mmoles, 98%) (Found: C, 22.6; H, 2.5. $C_3H_4F_4OSi$ requires C, 22.5; H, 2.5%) as a clear, colourless, viscous oil.

On a larger scale methyl-1: 1: 2: 2-tetrafluoroethyldichlorosilane (6·28 g., 29·2 mmoles) was slowly added to a stirred mixture of water (20 ml.) and ether (20 ml.) at 15—20°. The hydrolysis is exothermic. The ethereal solution was dried (Na_2SO_4) and the ether removed by distillation,

⁸ Barr and Haszeldine, J., 1955, 1881.

to leave the silicone (3.91 g., 84%). The oil was heated to 180° without decomposition or signs of distillation.

(b) Aqueous alkaline hydrolysis. Methyl-1:1:2:2-tetrafluoroethyldichlorosilane (0.0893 g., 0.415 mmole) and 10% aqueous sodium hydroxide (10 ml.), shaken at 20° for 10 min., gave 1:1:2:2-tetrafluoroethane (0.405 mmole, 98%) (Found: M, 100. Calc. for $C_2H_2F_4$: M, 102), identified by means of its infrared spectrum.

Reactions of the Silicone (II).—(a) With aqueous alkali. The silicone (0.1996 g., 1.25 mmoles) reacted at room temperature with 10% aqueous sodium hydroxide (10 ml.), but the hydrolysis was expedited by heating the mixture at 100° for 10 hr. Distillation of the volatile product gave 1:1:2:2-tetrafluoroethane (1.2 mmoles, 96%) (Found: M, 102. Calc. for $C_2H_2F_4: M$, 102), identified spectroscopically. The polysiloxane $[CH_3 \cdot SiO_{1.5}]_n$ remaining was identified spectroscopically.

(b) Thermal decomposition. The silicone (0.660 g., 4.1 mmoles) in a platinum crucible was heated at 200° in vacuo in a platinum tube for 1 hr. The gaseous product (0.15 mmole) was removed as formed by condensation in a trap cooled in liquid oxygen. The temperature was next raised to 260° for 2 hr., a further amount (0.9 mmole) of gas being collected in a cooled trap. Finally, the temperature was raised to 320° for 1 hr.; further breakdown occurred to give gaseous product (0.6 mmole). The same gaseous product was produced at each temperature, and the combined material (1.65 mmoles) was washed with aqueous sodium hydroxide to remove silicon tetrafluoride and fractionated to give trifluoroethylene (1.2 mmoles, 47% based on the silicone destroyed) (Found: M, 84. Calc. for C_2HF_3 : M, 82), identified by means of its infrared spectrum. Distillation of the more volatile polymer occurred also to some extent during the pyrolysis, and this material (0.254 g., 1.59 mmoles, 39%), a thin colourless oil, condensed in the cooler parts of the pyrolysis tube.

Infrared Spectra.—Recorded on a Perkin-Elmer Model 21 with sodium chloride optics, these were:

 $CHF_2 \cdot CF_2 \cdot SiMeCl_2$ (vapour), 2980 (m), 1410 (w), 1379 (s), 1345 (m), 1272 (s), 1200 (s), 1110 (vs), 1062 (s), 1027 (s), 847 (w), 805 (s), 762 (s), 650 (w) cm.⁻¹.

Silicone (II) (film), 2975 (m), 1393, 1381 (m, doublet), 1345 (m), 1276 (s), 1204 (w), 1156 (vs), 1100 (vs, broad), 1017 (w), 785 (s), 646 (w) cm.⁻¹.

(w = weak, m = medium, s = strong, vs = very strong.)

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